II.   AMENDMENTS TO THE CLAIMS:

Please cancel claims 2-4 and 8 without prejudice. Kindly amend claims 1, 5, 6 and 7 as follows.

The following Listing of Claims replaces all prior listings, or versions, of claims in the above-captioned application.

Listing of Claims:

1. (Currently Amended) A gas supply facility for a chamber, <u>wherein the gas supply facility comprises</u><s>comprising</s>:

<u>(a) a chamber exhausted by a vacuum pump,</u>

_____ <u>(b)</u> a <s>plurality of</s> <u>first</u> pressure type flow <u>controller controlling a small flow quantity corresponding to</u>10% of a maximum flow rate of the gas supply facility to the chamber;

_____ <u>(b) a second pressure type flow controller controlling a large flow quantity corresponding to 90% of the maximum flow rate of the gas supply facility to the chamber, wherein the second pressure type flow controller is</u><s>controllers</s> connected in parallel <u>with the first pressure type flow controller</u>;

<u>(c)</u> a <u>third</u> controller <u>operably connected</u> to control <s>the</s> operation of <u>the first</u><s>an aforementioned plurality of</s> pressure type flow <u>controller and the second pressure type flow controller</u><s>controllers</s>; <s>and</s>

_____ <s>a chamber exhausted by a vacuum pump,</s> wherein

the <u>first</u> pressure type flow <s>rate</s> controller <u>and the second pressure type flow controller each</u> comprises

_____ i. an orifice<u>;</u><s>,</s>

_____ ii. a pressure detector provided on an upstream side of the orifice<u>;</u><s>,</s>

iii. a control valve provided on an upstream side of the pressure detector~~;~~ and

iv. a computation control part that computes~~wherewith a~~ gas flow rate Qc of gas passing through the orifice using~~is computed with~~ pressure P1 detected by the pressure detector and using ~~a~~ formula Qc = KP1, ~~(where K is constant)~~, so that~~and~~ a difference Qy with a~~the~~ set flow rate Qs is outputted as a driving signal output to the~~a~~ control valve so that a ~~as a driving signal, thereby maintaining the~~ ratio P1/P2~~,~~ of ~~a~~ pressure P1 on the upstream side of the orifice and ~~a~~ pressure P2 on the downstream side of the orifice is maintained at~~, as~~ approximately two or more, wherein~~and also allows~~ accurate flow control over a wide flow rate range is achieved because the first~~by making one of the~~ pressure type flow controller controls the small flow quantity~~controllers to be a controller to control the~~ gas flow rate range up to 10% of the maximum flow rate ~~to be~~ supplied to the~~a~~ chamber, while the second~~remaining~~ pressure type flow controller controls the large flow quantity gas flow rate range of about 10-100% of the maximum flow rate supplied to the chamber; and

wherein the third controller comprises

i. an input setting part that sets flow rate of gas supplied to the chamber; and

ii. a signal conversion part;

wherein the first pressure type flow controller is initially operated to control small flow quantity and when flow rate reaches 10% of the maximum flow rate the second pressure type flow controller is switched into operation, wherein first control signals for both the first pressure type flow controller and the second pressure type flow controller are provided by a signal conversion part thereby enabling accurate flow rate control over a wide flow rate range by remitting first control signals from

the signal conversion part to the first pressure type flow controller and the second

pressure type flow controllercontroller(s) comprise controller(s) to control the rest of

the gas flow rate range.

Claims 2 to 4 have been cancelled.

5. (Currently Amended) A gas supply facility to a chamber as claimed in Claim 1,

further comprising:

          (e) a rising rate setting mechanism operably connected to remit secondof

control signals to be remitted to the firstsaid pressure type flow controller and the second

pressure type flow controller so as to control a large flow rangecontrollers allotted for all the

flow rate ranges of the flow controllers, and said second pressure type flow controller

controlling the large flow quantity suppliescontrollers supply the set flow rate of gas after a

specified lapse of time following the remittance of the secondaforementioned control signals.

6. (Currently Amended) A method for internal pressure control of a chamber, the

method comprising the steps of:

          (a) continuously operating a vacuum pump to decompress, through an exhaust

line equipped with a conductance valve, a chamber supplied with a gas from a gas supply

facility equipped with a first pressure type flow controller controlling a small flow quantity

corresponding to10% of a maximum flow rate of the gas supply facility to the chamber and a

second pressure type flow controller controlling a large flow quantity corresponding to 90%

of the maximum flow rate of the gas supply facility to the chamber, wherein the second

pressure type flow controller is connected in parallel with the first pressure type flow

controller, and the first pressure type flow controller and the second pressure type flow

controller each comprises

    i. an orifice;

    ii. a pressure detector provided on an upstream side of the orifice;

    iii. a control valve provided on an upstream side of the pressure

detector; and

    iv. a computation control part that computes a first gas flow rate Q_c of

gas passing through the orifice using pressure $P1$ detected by the pressure detector and using

formula $Q_c = KP1$, where K is constant, so that a difference Q_y with a set flow rate Q_s is

outputted as a driving signal to the control valve so that a ratio $P1/P2$ of pressure $P1$ on the

upstream side of the orifice and pressure $P2$ on the downstream side of the orifice is

maintained at approximately two or more;

    (b) determining a relationshiprelationships between a gas supply flow rate and

an internal pressure of the chamber at both athe maximum degree and a minimum degree of

opening of the aforementioned conductance valve, respectively, to ascertain a first control

range for the -gas supply flow rate supplied to the chamber and a second control range of the

internal pressure of the chamber; and

    (c) regulating the first gas flow rate, while supplying gas from the gas supply

facility, so that the first gas flow rate reachesto the gas supply flow rate corresponding to a

desired setthe internal pressure of the chamber that is to be set, determined from the

relationship between the gas supply flow rate and the internal pressure of the chamber in

order, to maintain the chamber at the desired set pressure.

    7. (Currently Amended) A method for an internal pressure control of a chamber as

claimed in Claim 6, the method further comprisingcomrpsing the steps of:

(d) supplying the~~suppling a~~ chamber connected to both the~~a~~ gas supply facility and an exhaust system comprising the exhaust line having the~~a~~ conductance vale; and

(e) maintaining the~~an~~ internal pressure of the chamber at the~~a~~ set pressure by regulating both ~~an~~ opening of the conductance valve of the exhaust system and the~~a~~ supply flow rate of the gas supply facility.

8. (Cancelled)